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| APPLICATION NO. | FILING DATE | FIRST NAMED INVENTOR | ATTORNEY DOCKET NO. | CONFIRMATION NO. |
|---|-------------|----------------------|---------------------|------------------|
| 10/646,709 | 08/25/2003 | Sadayuki Ohnishi | Q76993 | 9821 |
| 23373 7590 02/12/2008 SUGHRUE MION, PLLC 2100 PENNSYLVANIA AVENUE, N.W. | | | EXAMINER | |
| | | | CAO, PHAT X | |
| SUITE 800 WASHINGTON, DC 20037 | | | ART UNIT | PAPER NUMBER |
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Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

| | Application No. | Applicant(s) | | | | |
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| Office Action Comment | 10/646,709 | OHNISHI, SADAYUKI | | | | |
| Office Action Summary | Examiner | Art Unit | | | | |
| | Phat X. Cao | 2814 | | | | |
| The MAILING DATE of this communication app Period for Reply | ears on the cover sheet with the c | orrespondence address | | | | |
| A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING DA - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period w - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b). | ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be timularly and will expire SIX (6) MONTHS from cause the application to become ABANDONE | √. nely filed the mailing date of this communication. D (35 U.S.C. § 133). | | | | |
| Status | | | | | | |
| 1) Responsive to communication(s) filed on 16 No. | <u>ovember 2007</u> . | | | | | |
| 2a)⊠ This action is FINAL . 2b)□ This | This action is FINAL . 2b) This action is non-final. | | | | | |
| 3) Since this application is in condition for allowar | Since this application is in condition for allowance except for formal matters, prosecution as to the merits is | | | | | |
| closed in accordance with the practice under E | x parte Quayle, 1935 C.D. 11, 45 | 53 O.G. 213. | | | | |
| Disposition of Claims | | | | | | |
| 4) ☐ Claim(s) 27-32,34 and 35 is/are pending in the 4a) Of the above claim(s) is/are withdraw 5) ☐ Claim(s) is/are allowed. 6) ☐ Claim(s) 27-32,34 and 35 is/are rejected. 7) ☐ Claim(s) is/are objected to. 8) ☐ Claim(s) are subject to restriction and/or | vn from consideration. | | | | | |
| Application Papers | | | | | | |
| 9) The specification is objected to by the Examine | | | | | | |
| 10)☐ The drawing(s) filed on is/are: a)☐ acce | | | | | | |
| Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a). | | | | | | |
| Replacement drawing sheet(s) including the correcting 11) The oath or declaration is objected to by the Ex- | | | | | | |
| Priority under 35 U.S.C. § 119 | | | | | | |
| 12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority documents 2. Certified copies of the priority documents 3. Copies of the certified copies of the prior application from the International Bureau * See the attached detailed Office action for a list of | s have been received. s have been received in Applicati ity documents have been receive I (PCT Rule 17.2(a)). | on No ed in this National Stage | | | | |
| Attachment(s) 1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO/SB/08) Paper No(s)/Mail Date | 4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal P 6) Other: | nte | | | | |

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DETAILED ACTION

Claim Rejections - 35 USC § 103

1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

- (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 27, 29-32, and 34-35 are rejected under 35 U.S.C. 103(a) as being unpatentable over Barth et al (US. 2004/0173908) in view of Lauterbach et al (US 6,313,517).

Regarding claims 27 and 29-30, Barth (Fig. 1) discloses a semiconductor substrate 10, and a metal wiring 15 and an interlayer dielectric film (17,18,19) which are formed on the semiconductor substrate 10, the interlayer dielectric film (17,18,19) including a multi-layered structure consisting of: a diffusion barrier film 17 preventing diffusion of the metal out of the metal wiring 15 (par. [0006], last 3 lines), an adhesive film 18 (par. [0007]) formed directly on the diffusion barrier film 17, and a low dielectric constant film 19 of polymeric thermoset material (i.e., SILK) (par. [0008], lines 1-7) formed directly on the adhesive film 18, the low dielectric constant film 19 (or 119 in Fig. 2) being constituted essentially by an organic low dielectric constant material having a specific dielectric constant not greater than 4 (par. [0031]), and the organic low dielectric constant material 19 (Fig. 1) or 119 (Fig. 2) being a silicon-containing organic compound of

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methylsilsequioxane or SiOC (par. [0031]), and the diffusion barrier film 17 containing silicon (i.e., silicon nitride, par. [0006], last 3 lines).

Barth does not disclose that the adhesive film 18 is a silicon-based compound having an aromatic ring.

However, Lauterbach (column 3, lines 35-66 through column 4, lines 1-16) teaches the well-known feature of having polymer benzocyclobutene film being a silicon-containing organic compound having an aromatic ring (see formula at column 4) for providing a good adhesion to the metal wiring layer/dielectric layer (column 4, lines 10-13). Accordingly, in view of teaching of Barth that the adhesive film can be composed of any material suitable for enhancing adhesion of the dielectric layer (par. [0033]) and in view of teaching of Lauterbach that the benzocyclobutene silicon-based compound having an aromatic ring provides the good adhesion to the metal wiring/dielectric layer (column 4, lines 10-13), it would have been obvious to form the adhesive film 18 of Barth with the silicon-based compound material as set forth above because such silicon-containing organic compound BCB adhesive layer would provide a good adhesion to the metal wiring layer/organic dielectric layer, as taught by Lauterbach (column 4, lines 10-13).

Regarding claim 31, Lauterbach (column 3, lines 50-66 through column 4, lines 1-16) also teaches the forming of an adhesive BCB, the adhesive BCB is a polymer silicon-based compound formed through polymerization of a monomer containing a divinylsiloxane bisbenzocyclobutene unit.

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Regarding claims 32 and 34, Barth further discloses that the organic low dielectric constant material 19 (Fig. 1) or 119 (Fig. 2) is a silicon-containing organic compound of methylsilsequioxane or SiOC (par. [0031]).

Regarding claim 35, Barth's Fig. 1 also discloses the interlayer dielectric film (17,18,19) is formed on the metal wiring 15.

3. Claim 28 is rejected under 35 U.S.C. 103(a) as being unpatentable over Barth et al and Lauterbach et al as applied to claim 27 above, and further in view of Applicant's admitted prior art.

Barth discloses the diffusion barrier film 17 being made of SiN (par. [0006], last 3 lines), but does not disclose the diffusion barrier film 17 being made of SiCN.

However, Applicant's admitted prior art (Fig. 3) teaches the contact structure including a diffusion barrier film 108 of SiCN formed on a metal wiring 106. Accordingly, it would have been obvious to substitute SiN with SiCN because they both have the same function as a diffusion barrier film for preventing diffusion of the metal out of the metal wiring.

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Response to Arguments

4. In regard to the combination of Barth and <u>Lauterbach</u>, Applicant argues that one skilled in the art would not have been motivated to use the siliconcontaining BCB in <u>Lauterbach</u> as an adhesion promoting layer 18 of <u>Barth</u> for the purpose of obtaining the adhesion to the dielectric layer 19.

This argument is not persuasive because in view of teaching of <u>Barth</u> that the adhesive film can be composed of <u>any material</u> suitable for enhancing adhesion of the dielectric layer 19 (par. [0033]) and in view of teaching of <u>Lauterbach</u> that the benzocyclobutene silicon-based compound would provide the good adhesion to the metal wiring/dielectric layer (column 4, lines 10-13), one skilled in the art would have been motivated to combine the references as suggested.

Conclusion

5. Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be

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calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

6. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Phat X. Cao whose telephone number is 571-272-1703. The examiner can normally be reached on M-F.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Wael Fahmy can be reached on 571-272-1705. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

/P. X. C./ Primary Examiner, Art Unit 2814 /Phat X Cao/ Primary Examiner, Art Unit 2814

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